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# Surface acidity of $V_2O_5/Al_2O_3$ catalysts: IR and TPD studies

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#### Abstract

 $V_2O_5/Al_2O_3$  catalysts of different vanadium contents were prepared by contacting powdered  $\gamma$ -Al\_2O<sub>3</sub> with aqueous solutions of different concentrations of NH<sub>4</sub>VO<sub>3</sub>. Calcined catalysts with vanadium loadings below the monolayer coverage of Al<sub>2</sub>O<sub>3</sub> possessed adsorbed V-oxide layer which resisted dissolution in an ammoniacal solution. On the other hand, those catalysts of higher vanadium loadings had adsorbed V-oxide layer as well as precipitated crystalline V<sub>2</sub>O<sub>5</sub>. The latter preferentially dissolved in NH<sub>4</sub>OH solution. Infrared studies of chemisorbed NH<sub>3</sub> on V-Al-oxide catalysts as well as temperature programmed desorption (TPD) of NH<sub>3</sub> from these materials are reported. These studies revealed the existence of two kinds of both Lewis and Brønsted acidic sites. Below the monolayer coverage, Lewis acidity originated from Al ions uncovered with vanadia, whereas at high loadings of vanadia, this acidity is attributed to the unsaturated vanadyl groups. Regarding the Brønsted acidity, the V-OH species of the adsorbed V-oxide and the V-OH species of precipitated V<sub>2</sub>O<sub>5</sub> were shown to be responsible for this acidity. TPD results showed that the NH<sub>3</sub> was desorbed from Lewis acid sites by heating at ≈ 440 K and from Brønsted acid sites of adsorbed V-oxide at ≈ 640 K. At higher loadings of vanadium, the Lewis acidity was diminished due to coverage with precipitated V<sub>2</sub>O<sub>5</sub> particles by heating at ≈ 530 K. The various kinds of surface acidic sites were quantified by analysing the desorbed NH<sub>3</sub> from each kind of these sites. The present results assisted in confirming a proposed structure of the V-Al-oxide catalyst.

# 1. Introduction

There is a great interest in  $V_2O_5/Al_2O_3$  catalysts because of their wide range of applications in promoting various reactions, e.g. oxidation of SO<sub>2</sub>, CO and hydrocarbons [1-5], hydrogenation of CO and CO<sub>2</sub>, and more recently reduction of NO by  $NH_3$  [6–10]. As the catalytic activity of these materials is attributed, mainly, to their surface acidic properties [11-18], these characters have been the subject of several studies employing IR of  $NH_3$ and pyridine adsorption [11,12,14,17,18]. According to these studies,

these catalysts exhibit both Lewis and Brønsted acidic characters [11,12,14–18].

It is generally accepted that the interfacial interaction between a solid substrate and a solid adsorbate as well as the extent of loading of the adsorbate greatly influence the surface structure and consequently the distribution of the various surface sites. Hence several authors have investigated the effect of these parameters on the surface structure of V-Al-oxide catalysts [2,11,17-21]. These studies suggested the formation of isolated vanadyl groups as well as two-dimensional network of vanadia species on  $Al_2O_3$  surface at very low loadings of vanadia [2,21], whereas at higher

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loadings, the formation of complex surface polymeric compounds as well as crystallite lamellae of  $V_2O_5$  were proposed [2,11,17,18].

To gain full identification of the surface acidic properties, few points must still be elucidated. The nature of interaction between vanadium oxide and the external surface of the carrier is to be investigated; possibly by testing the solubility of the surface vanadia in a solvent, e.g.  $NH_4OH$ . Also the influence of ways of interaction on the surface acidity may be established by IR study of chemisorbed  $NH_3$ . Moreover, a quantitative determination of the various surface sites is still necessary for complete identification of surface acidity; this can be done by applying temperature programmed desorption (TPD) of a gas with a basic character, e.g.  $NH_3$  to the surface.

The present paper reports on the preparation of V–Al-oxide catalysts by the wet-impregnation method, and testing the solubility of these catalysts in  $NH_4OH$  solution with the objective of determining whether the interaction of vanadia with  $Al_2O_3$  is strong via an adsorption process, or weak via a precipitation process. An IR study is also described concerning the identification of surface acidic sites by adsorbing  $NH_3$ . In addition, TPD of  $NH_3$  is also presented aiming at determining quantitatively the various acidic sites.

# 2. Materials and methods

### 2.1. Preparation of sample

Aluminum hydroxide (Merck > 99%) was calcined in air at 773 K for 2 h to obtain  $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (surface area 183 m<sup>2</sup> g<sup>-1</sup>). Ammonium metavanadate (Fluka 99%), oxalic acid (Merck 98%), vanadium pentaoxide (BDH 99.9%), ammonia (BDH 99.98%) and ammonia solution (AnalaR) were used without further purification. Aluminum oxide (1.0 g) was impregnated in aqueous solution of various concentrations of ammonium metavanadate in 100 ml, oxalic acid (1.0 M) for 30 min. at 25°C. The homogenized slurries were adjusted to 7 pH units by adding NH<sub>4</sub>OH and  $HNO_3$  solution. The slurries were filtered, after centrifugation and washed several times with triple distilled water.

#### 2.2. Analysis of dissolved vanadium

The filtrate and the washing solutions were transferred quantitatively and analysed colorimetrically for the soluble vanadium ions by the 8-hydroxyquinoline method [22]. According to this method, vanadium(V) was extracted from the aqueous solution at pH 2 by a solution of 8-hydroxyquinoline in chloroform (0.05 M) as vanadium (V) oxinate. The extract was dissolved in chloroform and analyzed colorimetrically by measuring the absorption at 550 nm.

## 2.3. BET surface area measurements

Each slurry was dried at 373 K (15 h), ground, calcined in flowing air at 773 K (3 h) and allowed to cool to room temperature. Multipoint BET surface area measurements were performed by using NOVA-1000 gas sorption analyzer (Quantachrome Corporation). Nitrogen was used as an adsorbate at 77 K. Naming of the samples according to the vanadium loadings as well as values of surface areas are summarized in Table 1.

#### 2.4. The monolayer catalyst

A theoretical monolayer coverage of  $V_2O_5$  on  $Al_2O_3$  is predicted by considering an average V–V distance of 3.4 Å [19,21], thus a value of 4.4 V nm<sup>-2</sup> (or 1.31 mmol V/g  $Al_2O_3$ ) is expected for such a coverage on a 183 m<sup>2</sup> g<sup>-1</sup>  $Al_2O_3$  surface [19,21]. The theoretical monolayer catalyst was prepared by contacting 1.0 g of  $Al_2O_3$  to 1.31 mmol NH<sub>4</sub>VO<sub>3</sub> in 100 ml of 1.0 M oxalic acid solution. This mixture was heated at 393 K to complete dryness, and was then calcined in air at 773 K (3 h).

#### 2.5. Solubility of the adsorbed vanadium

A quantity of 1.0 g of each calcined catalyst was suspended in 100 ml 20% ammonia solution

Sample *	$NH_4VO_3$ (mmol) added to 1.0 g $Al_2O_3$	Vanadium <sup>a</sup> content (mmol/g Al <sub>2</sub> O <sub>3</sub> )	Vanadium dissolved <sup>c</sup> in NH <sub>4</sub> OH solution mmol/g catalyst	BET surface area of calcined catalysts $m^2 g^{-1}$
AV <sub>0.50</sub>	0.50	0.50	0.00	166
AV <sub>0.80</sub>	0.80	0.80	0.00	150
AV1 24	1.31 <sup>b</sup>	1.24	0.11	124
AV	1.13	1.13	0.00	128
AV142	1.60	1.42	0.18	112
AV4 65	5.00	4.65	3.22	52
AV <sub>5.21</sub>	6.00	5.21	3.93	46

Table 1 Adsorption of vanadium(V) from aqueous  $NH_4VO_3$  on  $Al_2O_3$  and its dissolution from calcined  $V_2O_5/Al_2O_3$  catalysts into  $NH_4OH$ 

<sup>a</sup> Numbers refer to mmols V adsorbed on 1.0 g  $Al_2O_3$  as calculated by quantifying the vanadium(V) concentration remaining in the filtrate and the washing solutions.

<sup>b</sup> mmol of NH<sub>4</sub>VO<sub>3</sub> corresponding to the theoretical monolayer coverage of Al<sub>2</sub>O<sub>3</sub> by V-oxide (Ref. [19,21]).

° 1.0 g of each calcined catalyst (773 K in air) was suspended in 100 ml 20% NH₄OH for 30 min under continuous stirring.

for 30 min with continuous stirring. The solubilities of vanadium(V) from the catalysts into the solution were determined colorimetrically by the 8-hydroxyquinoline method [22].

#### 2.6. Chemisorption of ammonia

Chemisorption of NH<sub>3</sub> was established by placing the powdered catalyst in a glass boat inside a 15 cm, 14 mm i.d., glass tube reactor. The catalysts were activated by heating at 773 K (1 h) with a tubular furnace in a flow of He gas (Fluka  $\approx 99\%$ ) previously purified by passing over oxygen trap. To prevent physisorption of NH<sub>3</sub>, the catalysts were kept at 393 K during the experiment [14]. NH<sub>3</sub> was introduced into the reactor at a rate of 20 cm<sup>3</sup> min<sup>-1</sup> for 30 min. The unadsorbed NH<sub>3</sub> gas was then flushed out of the reactor by flowing He at 393 K for 1 h.

#### 2.7. IR analysis

IR spectra for  $Al_2O$ ,  $V_2O_5$  and calcined V–Al oxide catalysts were recorded on a Shimadzu FTIR 8101M infrared spectrometer. This was carried out before and after treatment with NH<sub>3</sub> by using self-supporting pressed discs (50 mg and 13 mm diameter). The spectral width was 4 cm<sup>-1</sup> at 1000 cm<sup>-1</sup>.

# 2.8. Temperature programmed desorption (TPD) measurements

(TPD) experiments were carried out on 200 mg of the catalyst after adsorbing NH<sub>3</sub> under the previous conditions. The catalyst temperature was adjusted to 323 K. A stream of He at a rate of 20  $cm^3 min^{-1}$  was allowed to pass over the catalyst, then through a thermal conductivity detector (TCD) (Pye Unicam) which was connected to the glass reactor. The current leads of the TCD as well as those of a chromel-alumel thermocouple were connected to an X-Y recorder. The thermocouple was encapsulated inside a glass tube and placed touching the powdered samples. The thermal conductivity of the desorbed NH<sub>3</sub> was plotted as a function of the catalyst temperature in the range 325 to 823 K. Heating rate was linear, at 10°C/min, by controlling the input voltage to the furnace.

# 2.9. Quantitative determination of surface acidic sites

To quantify the desorbed  $NH_3$  in order to determine the various acidic sites, 100 mg of the catalyst was treated in a flow of  $NH_3$  as described before. After degasing the unadsorbed  $NH_3$ , the catalyst was heated at 503 K, then 563 and then at 723 K for 20 min in each case. The desorbed  $NH_3$ , after each heating stage, was carried out in a stream of  $N_2$  and trapped in a cold solution of 0.1 M HCl. NH<sub>3</sub> in the trap solution was analysed colorimetrically by the trichloramine method [23]. The different surface acidic sites were determined by quantifying the desorbed NH<sub>3</sub> at various temperatures.

## 3. Results and discussion

### 3.1. Adsorption of vanadium oxide on alumina

Table 1 lists the amount of vanadium adsorbed on 1.0 g Al<sub>2</sub>O<sub>3</sub> using various concentrations of NH<sub>4</sub>VO<sub>3</sub>. After calcination at 773 K, the amount of vanadium (V) dissolved in an ammoniacal solution as well as the BET surface areas of the catalysts are also listed in Table 1. This table shows that when Al<sub>2</sub>O<sub>3</sub> powder is suspended in  $NH_4VO_3$  solution of concentration less than that of the theoretical monolayer coverage, (i.e.  $< 1.31 \text{ mmol V/g Al}_2O_3$ ), complete adsorption of vanadium on Al<sub>2</sub>O<sub>3</sub> surface was established. On the other hand, at concentrations of vanadium higher than the monolayer coverage, complete adsorption of vanadium was not observed. Furthermore, catalysts of lower vanadium content were resistant to dissolution in the ammoniacal solution, whereas those catalysts of higher vanadium loading were partially dissolved in NH<sub>4</sub>OH. These results are indications of strong interaction between vanadia and alumina at low vanadia loadings, and weaker bonding between them at high loadings.

The interaction of vanadium oxycompounds with the external surface of  $Al_2O_3$  can either be strong via an adsorption process, or weak due to a precipitation process. The metavanadate anions in the aqueous solution of pH 7, formed polymeric species, via V-O-V bridges, whose degree of polymerization increased with the increase of the vanadium concentration [24]. Therefore, the adsorption of the polyvanadate species on  $Al_2O_3$ surface could possibly lead, via V-O-Al bridges, to the formation of a system like that shown in



Scheme 1, where *n* is the degree of polymerization. According to this scheme, the vanadium surface compounds exist in the form of two dimensional network on the alumina surface [2,19,21]. These polymeric surface species existed even at a very low vanadium coverage [17,25,26], however, the possibility of forming isolated VO<sub>4</sub> species is not excluded [17]. Because of the relatively strong interaction of vanadium with alumina surface via V–O–Al, V– O–V and V–V bonds, these catalysts were resistant to dissolution in NH<sub>4</sub>OH solution as indicated by the results in Table 1.

At higher loadings of vanadium, the degree of aggregation of polyvanadate anion, in the aqueous solution, was increased [24]. Further polymerization could even proceed after adsorbing the polyvanadate. This polymerization would propagate parallel and perpendicular to the alumina surface through V–O–V and/or V–V bridge, leading to the formation of a surface complex on  $Al_2O_3$  [2,11,17,18].

In addition to the above adsorption process, at relatively high vanadium loadings, a precipitation process of vanadium oxycompounds could occur inside the pores of the carrier. Upon calcination, these precipitates could form  $V_2O_5$  crystallites [11,17,18]. Precipitates of  $V_2O_5$  usually form layers of  $[VO_5]_n$ . These layers are built up from  $VO_5$  square pyramidal units, the assembly could hold to the alumina surface via Van der Waals interaction [21,26]. As the interaction of vanadia with alumina via the precipitation process, i.e. through the Van der Waals forces, is known to be weaker than the interaction via the previous adsorption process, one expects therefore that NH<sub>4</sub>OH would preferentially dissolve these vanadia precipitates [17,18,27]. Moreover, during the preparation of high vanadium content cataTable 2

Catalyst	V=0	O strete	ching	Coordinately held NH <sub>3</sub>	H <sub>3</sub>	Adsorbed NH <sub>4</sub> <sup>+</sup> on						
							OH of V	-oxide adsort	bed on Al <sub>2</sub> O <sub>3</sub>	OH of	V <sub>2</sub> O <sub>5</sub> preci	ipitated on Al <sub>2</sub> O <sub>3</sub>
	F	L	R	F	L	R	F	L	R	F	L	R
Al <sub>2</sub> O <sub>3</sub>	_	_	_	1235	1244, 1235, 1230	11, 14 17, 18, 29–33	-	-	_	_	_	_
$V_2O_5$	102	3 1020	17,18		-	~	-	-	_	1420	1420	11,17,18,33
AV <sub>0.50</sub>		-	-	1235			1454	1450		-	-	-
AV <sub>0.80</sub>	-	_	-	1235	-	-	1454	1450		-	-	_
AV <sub>1.31</sub> <sup>a</sup>	102	3 -		1235	-	-	1450	-	-	1420	-	-
AV <sub>4.65</sub>	102	5 -	-	1235	-	-	1450	_	-	1425	-	-
AV <sub>5.21</sub>	102	5 –	-	-	-	-	1450	-	-	1425	-	_

IR absorption bands,  $cm^{-1}$ , of Al<sub>2</sub>O<sub>3</sub>, V<sub>2</sub>O<sub>5</sub> and V-Al-oxide catalysts as well as those of chemisorbed NH<sub>3</sub> on the same materials

F = found; L = literature; R = reference.

<sup>a</sup> The monolayer catalyst.

lysts, residuals of vanadium(V) ions were remaining in the solution, possibly, due to the equilibrium between the precipitated and the aqueous vanadate species. This equilibrium could be shifted towards the formation of surface vanadium/alumina compounds at low concentrations of vanadium due to the predominance of the vanadium adsorption process.

#### 3.2. Infrared (IR) studies

Table 2 lists the IR data of different  $V_2O_5/Al_2O_3$  catalysts as well as those of  $Al_2O_3$  and  $V_2O_5$ . An IR band at 1023 cm<sup>-1</sup> was displayed by catalysts of monolayer or higher vanadium content and also by  $V_2O_5$ . This band is assigned to the stretching vibration of V=O [17,18,28,29]. As for catalysts of vanadium content less than the monolayer composition they did not exhibit the 1023 cm<sup>-1</sup> band, therefore, they did not possess vanadyl group.

The IR data of ammonia adsorbed on the calcined catalysts are also listed in Table 2. The data of ammonia adsorbed on  $Al_2O_3$  and  $V_2O_5$  are also included in this Table. The  $V_2O_5/Al_2O_3$  catalysts as well as  $Al_2O_3$  itself always exhibited strong peaks around 3500 and 1650 cm<sup>-1</sup> due to H<sub>2</sub>O adsorption, thus we focused on the spectra in the region below 1600 cm<sup>-1</sup> in the following results and discussion.

The IR spectrum of  $NH_3$  adsorbed on  $Al_2O_3$ exhibited one absorption band at  $1253 \text{ cm}^{-1}$  due to coordinatively held NH<sub>3</sub> to Lewis acid sites [11, 14, 17, 18, 30-33]. It is documented that Al<sub>2</sub>O<sub>3</sub> does not possess Brønsted acidity, in accordance with our results. In the IR spectrum of the monolayer catalyst as well as in those of lower vanadium content, the band of the coordinately held ammonia  $(1235 \text{ cm}^{-1})$  and another band at 1450 were displayed. The latter band is assigned to NH<sub>3</sub> adsorbed on Brønsted acid sites of vanadia adsorbed on alumina [11,17,18,29-33]. The intensity of the 1235  $\text{cm}^{-1}$  band, for coordinately held NH<sub>3</sub>, decreased gradually with vanadium coverage, until it vanished completely for the  $AV_{5,21}$  catalyst. In the meantime, these catalysts exhibited another IR band at 1420  $\text{cm}^{-1}$ . This band is assigned to the adsorption of NH<sub>3</sub> on Brønsted acid sites located on particles of  $V_2O_5$ precipitated on Al<sub>2</sub>O<sub>3</sub> surface [11,17,18]. There is a strong correlation between the appearance of the 1420 cm<sub>-1</sub> IR absorption band and the dissolution of the  $V_2O_5/Al_2O_3$  catalysts in NH<sub>3</sub> (Table 1 and Table 2), indicating the formation of  $V_2O_5$  particles due to precipitation on Al<sub>2</sub>O<sub>3</sub> surface at high loadings of vanadium. As crystalline V<sub>2</sub>O<sub>5</sub> does not possess Lewis acidic sites [11,33], therefore the disappearance of the 1235  $cm^{-1}$  IR absorption band for AV<sub>5.21</sub>, after adsorbing NH<sub>3</sub>, indicates complete coverage of V<sub>2</sub>O<sub>5</sub>/



Temperature. K Fig. 1. Temperature programmed desorption ammonia profiles for alumina and vanadia-alumina catalysts.

 $Al_2O_3$  surface with particles of crystalline  $V_2O_5$ . This is further proof for the formation of  $V_2O_5$ precipitates on  $V_2O_5/Al_2O_3$  surface.

#### 3.3. Thermal programmed desorption (TPD)

Fig. 1 shows the relationship between the thermal conductivity of the desorbed NH<sub>3</sub> and the linear increase in temperature for Al<sub>2</sub>O<sub>3</sub> as well as for different V<sub>2</sub>O<sub>5</sub>/Al<sub>2</sub>O<sub>3</sub> catalysts. The TPD profile of Al<sub>2</sub>O<sub>3</sub> is characterized by one strong NH<sub>3</sub> desorption peak at  $\approx$  440 K and a weaker peak at  $\approx$  810 K. These two peaks were assigned to the desorption of coordinately held NH<sub>3</sub> from Lewis acid sites of different strength [14]. Table 3 shows that the number of Lewis acid sites on Al<sub>2</sub>O<sub>3</sub> is 2.8 × 10<sup>14</sup> site cm<sup>-2</sup>. This value is comparable to the literature value (3.38 × 10<sup>14</sup> site cm<sup>-2</sup> [14]).

In the TPD spectra of catalysts of vanadium content lower than the monolayer coverage  $(AV_{0.50} \text{ and } AV_{0.80})$ , the intensities of the 440 K NH<sub>3</sub> desorption peak have decreased and the peak at 810 K has completely vanished. Furthermore, an intense peak for NH<sub>3</sub> appeared at  $\approx 640$  K. The 440 K NH<sub>3</sub> desorption peak is assigned, as in the case of Al<sub>2</sub>O<sub>3</sub>, to desorption from Lewis acid sites, while the other peak at 640 K is attributed to the desorption of NH<sub>3</sub> from Brønsted acid sites of vanadium oxide adsorbed on alumina. This was further supported by IR results of these catalysts after desorbing NH<sub>3</sub> by heating at 503 K and then,

0.0

15

22

Catalyst	Lewis acid site $cm^{-2} \times 10^{14} a$	Brønsted acid site on adsorbed vanadia $cm^{-2} \times 10^{14 b}$	Brønsted acid site on crystalline $V_2O_5$ cm <sup>-2</sup> ×10 <sup>14</sup> c		
Al <sub>2</sub> O <sub>3</sub>	2.8	0.0	0.0		
AV <sub>0.50</sub>	2.1	5.1	0.0		
AV <sub>0.80</sub>	1.4	7.1	0.0		

Numbers of different acidic sites on V2O5/Al2O3 catalyst as determined by quantifying the desorbed NH3

7.6

5.2

4.1

<sup>a</sup> As determined by quantifying the desorbed  $NH_3$  at 503 K, via the trichloramine method [23], and assuming that each  $NH_3$  molecule was bound to a Lewis acid site.

<sup>b</sup> As in the case of footnote a but heating at 723 K.

<sup>c</sup> As in the case of footnote a but heating at 563 K.

3.4

0.4

0.0

d The monolayer catalyst.

Table 3

AV1.31 d

AV4.65

AV<sub>5.21</sub>

The number of different acidic sites is shown in Table 3. From this table it is clear that the number of Lewis acid sites is less than the case of Al<sub>2</sub>O<sub>3</sub>; revealing that some of these sites are covered with V-oxide. Furthermore, the ratio of Brønsted acid sites to V atoms is 2.8 and 2.2 in the case of  $AV_{0.50}$  and  $AV_{0.80}$  catalysts, respectively. These ratios indicate that most of the vanadia species were in the form of isolated vanadyl groups, as each isolated vanadyl species could have three O-H groups. For the monolayer catalyst, although the Al<sub>2</sub>O<sub>3</sub> surface was covered with more V-oxide in comparison to  $AV_{0.50}$  and  $AV_{0.80}$ catalysts, the intensity of the 440 K TPD peak, characterizing the desorption of the coordinately held NH<sub>3</sub>, has unexpectedly increased. It is thus suggested that NH<sub>3</sub> was coordinately bound to unsaturated vanadium ions as well as to uncovered Al ions. These vanadium ions could be regarded as Lewis acid sites [12]. Indeed the IR spectrum of the monolayer catalyst, Table 2, displayed an IR absorption band at 1023  $\text{cm}^{-1}$  assignable to the stretching vibration of vanadyl groups of the monolayer catalyst. Regarding the Brønsted acid sites on the monolayer catalyst, a value of 1.4 Brønsted acid site/V is predicted from Tables 1 and 3. This is a low value compared to those of the lower vanadium loadings catalysts. As the vanadium content was increased, the degree of polymerization of the surface vanadyl species would do likewise. Therefore, according to the structure of the catalyst in scheme 1, the OH groups of the vanadyl species, which were responsible for the Brønsted acidity, would be consumed in forming the V–O–V bridges of the polymeric surface species. Therefore, as suggested in Scheme 1, at very high values of n, the degree of polymerization, which increased with the increase in vanadium loadings, the ratio of OH groups to V atoms would decrease due to the consumption of V-OH species during polymerization.

As vanadium loading was increased, the TPD peak of coordinatively held NH<sub>3</sub> was decreased and completely vanished for AV<sub>5.21</sub> catalyst. In the meantime, an ammonia TPD shoulder was displayed at  $\approx 530$  K. The decrease in the Lewis acid activity with the increase in the vanadia loadings is in accordance with the enhanced formation of crystalline  $V_2O_5$  which exhibits only Brønsted acidity [11,33]. In order to probe the nature of this shoulder, IR spectra of the high vanadium loadings catalysts (AV<sub>4.65</sub> and AV<sub>5.21</sub>) were taken, before, and after, desorbing NH<sub>3</sub> by heating at 563 K for 20 min. Before desorbing NH<sub>3</sub>, an IR band at 1425 cm<sup>-1</sup> was exhibited. This band is therefore assignable to NH<sub>3</sub> adsorbed on V-OH species of the precipitated vanadium pentoxide [11,17,18]. Moreover, this IR band has disappeared by heating, at 563 K. Therefore, the TPD shoulder at 530 K could be assignable to NH<sub>3</sub> desorbed from Brønsted acid sites of crystallite V<sub>2</sub>O<sub>5</sub> precipitated on Al<sub>2</sub>O<sub>3</sub> carrier.

# 4. Conclusion

(i) Vanadium oxide of low vanadium loadings resisted dissolution in an ammoniacal solution due to strong bonding to the  $Al_2O_3$  support via Al-O-V and V-O-V bridges. On the other hand, at higher vanadium loadings, particles of crystalline  $V_2O_5$  were precipitated on  $Al_2O_3$ , and thus dissolved in NH<sub>4</sub>OH solution.

(ii) The low vanadium loading catalysts exhibited Brønsted acidity due to V–O–H species and Lewis acidity due to uncovered Al ions. In addition to these sites, the monolayer catalyst exhibited Lewis acidity assignable to unsaturated vanadium ions.

(iii) Catalysts of high vanadium loadings exhibited two kinds of Brønsted acidity assignable to V-OH species of adsorbed V-oxide on  $Al_2O_3$ , and V-OH species of crystalline  $V_2O_5$ , whereas Lewis acidity was diminished due to coverage of the catalyst surface with particles of  $V_2O_5$ .

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